

IN THE

UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANTS:

Tony P. Chiang et al.

SERIAL NO.:

09/994,279

FILING DATE:

November 26, 2001

TITLE:

Method for Integrated In-Situ Cleaning and Subsequent

Atomic Layer Deposition Within a Single Processing

Chamber

EXAMINER:

David Nhu

GROUP ART UNIT:

2818

CONF. NO.:

8825

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PA1688US

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LETTER TO THE CHIEF DRAFTSMAN

SIR:

Subject to the approval of the Primary Examiner in the above-entitled patent application, please substitute the formal drawing sheets containing Figures 1, 4A and 4B for the sheets containing Figures 1, 4A and 4B previously submitted.

By:

Respectfully submitted,

Tony P. Chiang et al.

Dated: Sept. 26, 2002

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